

ABSTRACT

A cleaning composition for a hard disk substrate that has excellent cleanability for particles remaining on a substrate surface is provided.

The cleaning composition for a hard disk substrate includes a polymer
 5 (component A). The polymer (component A) contains: a constituent unit (a1) derived from a monomer a1 expressed by General Formula (I) below or an anhydride thereof and a constituent unit (a2) derived from at least one monomer a2 selected from a monomer expressed by General Formula (II) below and a monomer expressed by General Formula (III) below. The component A has a weight average molecular
 10 weight of 15000 or more and 200000 or less and a pH of 8 or higher.

